



Docket No.: M4065.0319/P319-A
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Ronald A. Weimer, et al.

Confirmation No.: 5990

Application No.: 09/912,558

Art Unit: 2813

Filed: July 26, 2001

Examiner: E. J. Kielin

For: FABRICATION OF DRAM AND OTHER
SEMICONDUCTOR DEVICES WITH AN
INSULATING FILM USING A WET RAPID
THERMAL OXIDATION PROCESS

By
ENTERED
FILED
RCE
9/30/04

AMENDMENT AFTER FINAL ACTION (37 C.F.R. SECTION 1.116)

Commissioner for Patents

MS: AF
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

This paper is in response to the Office Action dated July 20, 2004. Please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.